



Docket No.: 543822005300  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Steven WANG et al.

Application No.: 10/812,412

Confirmation Number: 1275

Filed: March 30, 2004

Art Unit: 2812

For: METHOD FOR PRODUCING A DEEP  
TRENCH CAPACITOR IN A  
SEMICONDUCTOR SUBSTRATE

Examiner: Not Yet Assigned

**SUBMISSION OF FORMAL DRAWINGS**

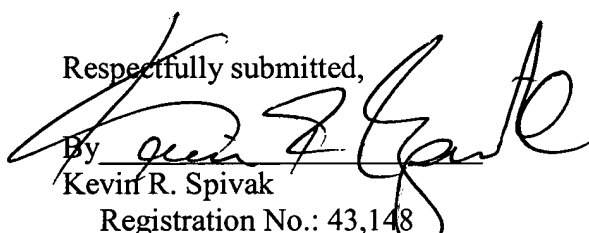
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Submitted herewith is one set (thirteen sheets, thirteen figures) of formal drawings for filing in the above-identified patent application. Kindly substitute the enclosed formal drawings for the informal drawings submitted with the originally filed application.

Dated: September 10, 2004

Respectfully submitted,

By   
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